

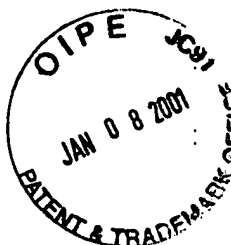
IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re application of

Tatsuhiko SHIBUYA et al.

Serial No. 09/302,471

Filed April 30, 1999



Docket No.00774/98-129 TOK/US

Group Art Unit 1755

Examiner D. Brunsman

SILICA-BASED COATING FILM ON
SUBSTRATE AND COATING SOLUTION
THEREFOR

THE COMMISSIONER IS AUTHORIZED
TO CHARGE ANY DEFICIENCY IN THE
FEE FOR THIS PAPER TO DEPOSIT
ACCOUNT NO. 23-0975.

RECEIVED
JAN 11 2001
1700 MAIL ROOM

RESPONSE

Assistant Commissioner for Patents,
Washington, D.C.

Sir:

This is in response to the Official Action dated September 18, 2000, the period for response having been extended for one month by the attached petition.

REMARKS

Favorable reconsideration is respectfully requested.

The claims are 1 to 16.

Claims 1-12 have been rejected under 35 USC 102(b) as being anticipated by Adachi et al. on the ground that the reference teaches a composition formed by mixing tetramethoxysilane, DMF, methanol, water and ammonia heated whereby the methanol would be driven off first to be replaced completely by DMF. This, however, appears not to be very pertinent to the subject matter of claims 1-6 directed to a coating solution and claims 7-12 directed to a method for the preparation of the coating solution, since the subject matter of Adachi et al. is a method for the preparation of silica glass by the sol-gel method and not a coating solution or method for preparation thereof.